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Frontiers in Ultrafast Optics: Biomedical, Scientific, and Industrial Applications XII

**Alexander Heisterkamp
Michel Meunier
Stefan Nolte**
Editors

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Contents

vii *Conference Committee*

SESSION 1 CELL MANIPULATION AND OPTOPORATION USING NANO- AND MICROPARTICLES

- 8247 06 **Nano particles insertion into individual mammalian cells using optical tweezers** [8247-05]
M. Waleed, J.-D. Kim, Y.-G. Lee, Gwangju Institute of Science and Technology (Korea, Republic of)

SESSION 2 LASER FABRICATION OF SCAFFOLDS AND ARTIFICIAL BIOSTRUCTURES

- 8247 08 **Femtosecond laser two-photon polymerization of three-dimensional scaffolds for tissue engineering and regenerative medicine applications** [8247-07]
V. Aprile, S. M. Eaton, M. Laganà, G. Cerullo, M. T. Raimondi, R. Osellame, Politecnico di Milano (Italy)

SESSION 3 NONLINEAR LASER SURGERY AND IMAGING

- 8247 0D **Neuronal rat cell imaging using a new UV-extended supercontinuum source** [8247-12]
S. Taccheo, Swansea Univ. (United Kingdom); S. Soria, Istituto di Fisica Applicata Nello Carrara (Italy); C. D'Andrea, Politecnico di Milano (Italy); K. Schuster, Institute of Photonic Technology (Germany); A. Bassi, R. Cubeddu, Politecnico di Milano (Italy); J. Kobelke, K. Mörl, Institute of Photonic Technology (Germany); G. Nunzi Conti, G. Righini, Istituto di Fisica Applicata Nello Carrara (Italy); F. Quercioli, Istituto Nazionale Ottica (Italy)

SESSION 4 ULTRASHORT LASER SYSTEMS FOR BIOMEDICAL

- 8247 0F **Alignment and maintenance free all-fiber laser source for CARS microscopy based on frequency conversion by four-wave-mixing** [8247-14]
M. Baumgartl, Friedrich-Schiller-Univ. Jena (Germany) and Helmholtz Institute Jena (Germany); M. Chemnitz, C. Jauregui, Friedrich-Schiller-Univ. Jena (Germany); T. Meyer, B. Dietzek, J. Popp, Friedrich-Schiller-Univ. Jena (Germany) and Institut für Photonische Technologien e.V. (Germany); J. Limpert, Friedrich-Schiller-Univ. Jena (Germany) and Helmholtz Institute Jena (Germany); A. Tünnermann, Fraunhofer-Institut für Angewandte Optik und Feinmechanik (Germany) and Helmholtz Institute Jena (Germany) and Fraunhofer Institute for Applied Optics and Precision Engineering (Germany)
- 8247 0G **Low noise laser system generating 26-fs pulse duration, 30-kW peak power, and tunability from 800- to 1200-nm for ultrafast spectroscopy and multiphoton microscopy** [8247-15]
B. Resan, F. Brunner, A. Rohrbacher, H. Ammann, K. J. Weingarten, Time-Bandwidth Products AG (Switzerland)

SESSION 5 ULTRAFAST LASER SYSTEMS AND MEASUREMENTS

- 8247 0H **High Q femtoREGEN UC laser systems for industrial microprocessing applications** [8247-16]
V. V. Matyilitsky, High Q Laser Innovation GmbH (Austria); P. Kubis, C. J. Brabec, Univ. Erlangen-Nürnberg (Germany) and ZAE Bayern (Germany); J. Aus der Au, High Q Laser Innovation GmbH (Austria)
- 8247 0I **Sub-picosecond laser amplifier with >1mJ pulse energy and 33W average power** [8247-17]
M. Delaigue, S. Ricaud, C. Hönninger, E. Mottay, Amplitude Systèmes (France)
- 8247 0J **Measuring two ultrashort pulses simultaneously using a single device and on a single shot** [8247-18]
T. C. Wong, J. Ratner, P. Vaughan, V. Chauhan, R. Trebino, Georgia Institute of Technology (United States)
- 8247 0K **Pulse repetition interval-based Excess Fraction method for an arbitrary and absolute distance measurement using a femtosecond optical frequency comb** [8247-19]
D. Wei, K. Takamasu, H. Matsumoto, The Univ. of Tokyo (Japan)

SESSION 6 PROCESSING OF TRANSPARENT MATERIALS I

- 8247 0L **Femtosecond laser waveguide writing for integrated quantum optics (Invited Paper)** [8247-20]
A. Crespi, Istituto di Fotonica e Nanotecnologie (Italy) and Politecnico di Milano (Italy); L. Sansoni, Sapienza Univ. di Roma (Italy); G. Vallone, Museo Storico della Fisica e Ctr. Studi e Ricerche Enrico Fermi (Italy) and Sapienza Univ. di Roma (Italy); F. Sciarrino, Sapienza Univ. di Roma (Italy) and Istituto Nazionale di Ottica (Italy); R. Ramponi, Istituto di Fotonica e Nanotecnologie (Italy) and Politecnico di Milano (Italy); P. Mataloni, Sapienza Univ. di Roma (Italy) and Istituto Nazionale di Ottica (Italy); R. Osellame, Istituto di Fotonica e Nanotecnologie (Italy) and Politecnico di Milano (Italy)
- 8247 0M **Femtosecond laser writing of polarization devices for optical circuits in glass** [8247-21]
L. A. Fernandes, Univ. of Toronto (Canada) and INESC Porto (Portugal); J. R. Grenier, P. R. Herman, J. S. Aitchison, Univ. of Toronto (Canada); P. V. S. Marques, INESC Porto (Portugal)
- 8247 0N **Enhanced formation of nanogratings inside fused silica due to the generation of self-trapped excitons induced by femtosecond laser pulses** [8247-22]
S. Richter, F. Jia, M. Heinrich, S. Döring, Friedrich-Schiller-Univ. Jena (Germany); S. Nolte, A. Tünnermann, Friedrich-Schiller-Univ. Jena (Germany) and Fraunhofer Institute of Applied Optics and Precision Engineering (Germany)

SESSION 7 PROCESSING OF TRANSPARENT MATERIALS II

- 8247 0Q **Formation dynamics of femtosecond laser-induced phase objects in transparent materials (Invited Paper)** [8247-25]
A. Mermillod-Blondin, A. Rosenfeld, Max-Born-Institut für Nichtlineare Optik und Kurzzeitspektroskopie (Germany); R. Stoian, E. Audouard, Lab. Hubert Curien, CNRS, Univ. de Lyon (France)

- 8247 OR **Density variation in fused silica exposed to femtosecond laser** [8247-26]
A. Champion, Y. Bellouard, Eindhoven Univ. of Technology (Netherlands)
- 8247 OT **On the role of the scanning line density on the etching of fused silica specimens exposed to femtosecond lasers pulses** [8247-28]
Y. Bellouard, Eindhoven Univ. of Technology (Netherlands); A. A. Said, M. Dugan, P. Bado, Translume, Inc. (United States)
- 8247 OU **Structural modification in Er-Yb doped zinc phosphate glasses with megahertz repetition rate femtosecond pulses** [8247-29]
N. Troy, L. B. Fletcher, Univ. of California, Davis (United States); S. T. Reis, R. K. Brow, Missouri Univ. of Science and Technology (United States); H. Huang, L. Yang, J. Liu, PolarOnyx, Inc. (United States); D. M. Krol, Univ. of California, Davis (United States)

SESSION 8 PROCESSING OF TRANSPARENT MATERIALS III

- 8247 OX **Rapid prototyping of biocompatible sensor chips by picoseconds laser structuring of a platinum/ tantalum pentoxide thin film layer system** [8247-32]
G. Heise, Munich Univ. of Applied Sciences (Germany); D. Trappendreher, Technische Univ. München (Germany) and Munich Univ. of Applied Sciences (Germany); F. Ilchmann, R. S. Weiss, B. Wolf, Technische Univ. München (Germany); H. P. Huber, Munich Univ. of Applied Sciences (Germany)
- 8247 OZ **Mechanism of selective removal of transparent layers on semiconductors using ultrashort laser pulses** [8247-34]
T. Rublack, S. Hartnauer, M. Mergner, M. Muchow, M. Schade, H. S. Leipner, Martin-Luther-Univ. Halle-Wittenberg (Germany); G. Seifert, Martin-Luther-Univ. Halle-Wittenberg (Germany) and Fraunhofer Ctr. für Silizium-Photovoltaik (Germany)

SESSION 9 ULTRAFAST LASER 3D-FABRICATION: JOINT SESSION WITH CONFERENCE 8243

- 8247 10 **Three-dimensional silver nanostructure fabrication through multiphoton photoreduction** [8247-35]
K. Vora, S. Kang, S. Shukla, E. Mazur, Harvard Univ. (United States)
- 8247 11 **Material specific effects and limitations during ps-laser generation of micro structures** [8247-36]
J. Hildenhagen, U. Engelhardt, M. Smarra, K. Dickmann, Muenster Univ. of Applied Sciences (Germany)

SESSION 10 FUNDAMENTALS AND DIAGNOSTICS IN ULTRAFAST LASER PROCESSING: JOINT SESSION WITH CONFERENCE 8243

- 8247 17 **Influence of pulse duration on the hole formation during short and ultrashort pulse laser deep drilling** [8247-42]
S. Döring, S. Richter, Friedrich-Schiller-Univ. Jena (Germany); A. Tünnermann, S. Nolte, Friedrich-Schiller-Univ. Jena (Germany) and Fraunhofer Institute for Applied Optics and Precision Engineering (Germany)

POSTER SESSION

- 8247 18 **Supercontinuum emission from water using fs pulses in the external tight focusing limit** [8247-45]
S. Sreeja, S. Venugopal Rao, Univ. of Hyderabad (India); P. Radhakrishnan, Cochin Univ. of Science and Technology (India); S. P. Tewari, P. Prem Kiran, Univ. of Hyderabad (India)
- 8247 1A **Compact laser pulser for TOF SPAD rangefinder application** [8247-47]
L. W. Hallman, Univ. of Oulu (Finland); K. Haring, L. Toikkanen, T. Leinonen, Tampere Univ. of Technology (Finland); B. S. Ryvkin, Univ. of Oulu (Finland) and Ioffe Physico-Technical Institute (Russian Federation); J. T. Kostamovaara, Univ. of Oulu (Finland)
- 8247 1C **Directly diode-pumped femtosecond laser based on an Yb:KYW crystal** [8247-49]
G. H. Kim, J. Yang, D. S. Lee, A. V. Kulik, E. G. Sall', S. A. Chizhov, V. E. Yashin, U. Kang, Korea Electrotechnology Research Institute (Korea, Republic of)
- 8247 1D **Development of an automatics joint-area-measurement system after ultrafast laser microwelding** [8247-50]
Y. Nonogaki, K. Okusu, M. Yoshimoto, T. Tamaki, Nara National College of Technology (Japan)

Author Index

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and Technology (Japan)

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1 Cell Manipulation and Optoporation Using Nano- and Microparticles
Alexander Heisterkamp, Friedrich-Schiller-Universität Jena (Germany)

2 Laser Fabrication of Scaffolds and Artificial Biostructures
Michel Meunier, Ecole Polytechnique de Montréal (Canada)

3 Nonlinear Laser Surgery and Imaging
Georg von Freymann, Nanoscribe GmbH (Germany)

- 4 Ultrashort Laser Systems for Biomedical
David Kleinfeld, University of California, San Diego (United States)
- 5 Ultrafast Laser Systems and Measurements
Michael M. Mielke, Raydiance, Inc. (United States)
- 6 Processing of Transparent Materials I
Michael Withford, Macquarie University Australia (Australia)
- 7 Processing of Transparent Materials II
Craig B. Arnold, Princeton University (United States)
- 8 Processing of Transparent Materials III
Alexandre Mermillod-Blondin, Max-Born-Institut für Nichtlineare Optik
und Kurzeitspektroskopie (Germany)
- 9 Ultrafast Laser 3D-Fabrication: Joint Session with Conference 8243
Yoshiki Nakata, Osaka University (Japan)
Beat Neuenschwander, Berner Fachhochschule Technik und Informatik
(Switzerland)
- 10 Ultrafast Laser-induced Modification of Glasses or Transparent
Materials: Joint Session with Conference 8243
Stefan Nolte, Friedrich-Schiller-Universität Jena (Germany)
- 11 Ultrafast Laser Surface Processing: Joint Session with Conference 8243
Beat Neuenschwander, Berner Fachhochschule Technik und Informatik
(Switzerland)
Yoshiki Nakata, Osaka University (Japan)
- 12 Fundamentals and Diagnostics in Ultrafast Laser Processing: Joint
Session with Conference 8243
Michel Meunier, Ecole Polytechnique de Montréal (Canada)